

# VLSI Devices

## Lecture 18

Sung-Min Hong ([smhong@gist.ac.kr](mailto:smhong@gist.ac.kr))

Semiconductor Device Simulation Laboratory

Department of Electrical Engineering and Computer Science

Gwangju Institute of Science and Technology (GIST)

# Coverage

- Two YouTube lectures reserved for advanced topics
  - L14: ~~Substrate bias, channel mobility~~
  - L15: ~~3.2.1~~
  - L16: ~~3.2.1 (Continued)~~
  - L17: Velocity saturation (3.2.2)
  - ➔ – L18: Channel length modulation and so on (3.2.3, 3.2.4, 3.2.5)
  - L19: MOSFET scaling
  - L20: MOSFET scaling (Continued)
  - L21: Quantum effect (4.2.4)
  - L22: Double-gate MOSFETs (10.3)
  - L23: FinFETs
  - L24: CFETs

# First-order expansion

- Keep only  $b_1$  and  $c_1$ . ( $u_B$  is neglected.)

– Then,

$$\begin{aligned}\phi(x, y) &= \phi_s \left(1 - \frac{x}{W_d}\right)^2 \\ &+ \frac{b_1 \sinh\left(\frac{\pi(L - y)}{\lambda}\right) + c_1 \sinh\left(\frac{\pi y}{\lambda}\right)}{\sinh\left(\frac{\pi L}{\lambda}\right)} \sin\left(\frac{\pi(x + 3_{tox})}{\lambda}\right)\end{aligned}$$

Taur, Eq. (A9.22)

- Approximate values for  $b_1$  and  $c_1$  are  $\frac{4}{\pi}(\phi_{bi} - a\phi_s)$  and  $\frac{4}{\pi}(\phi_{bi} + V_{ds} - a\phi_s)$ , respectively.  $a \approx 0.4$ .

# Surface potential

- At  $x = 0$ ,

$$\phi(0, y) = \phi_s + \frac{b_1 \sinh\left(\frac{\pi(L-y)}{\lambda}\right) + c_1 \sinh\left(\frac{\pi y}{\lambda}\right)}{\sinh\left(\frac{\pi L}{\lambda}\right)} \sin\left(\frac{\pi 3t_{ox}}{\lambda}\right)$$

Taur, Eq. (A9.22)

– Let's find the minimum potential.

$$\frac{d}{dy} \phi(0, y) = \frac{\pi}{\lambda} \frac{-b_1 \cosh\left(\frac{\pi(L-y)}{\lambda}\right) + c_1 \cosh\left(\frac{\pi y}{\lambda}\right)}{\sinh\left(\frac{\pi L}{\lambda}\right)} \sin\left(\frac{\pi 3t_{ox}}{\lambda}\right) = 0$$

$$b_1 \cosh\left(\frac{\pi(L-y)}{\lambda}\right) = c_1 \cosh\left(\frac{\pi y}{\lambda}\right)$$

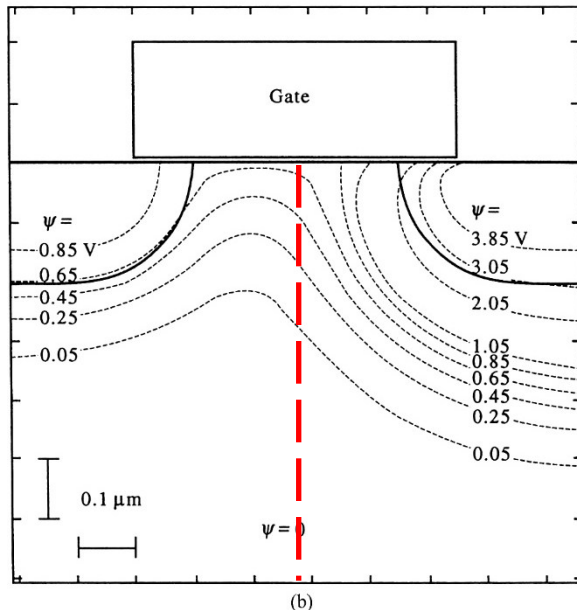
# Position for minimum potential, $y = y_c$

- For a positive  $z$ ,  $\cosh z \approx \frac{\exp z}{2}$ .

$$\exp \frac{\pi(L^2 - 2y_c)}{\lambda} = \frac{c_1}{b_1}$$

$$y_c = \frac{L}{2} - \frac{\lambda}{2\pi} \ln \frac{c_1}{b_1} \approx \frac{L}{2} - \frac{W_d + 3t_{ox}}{2\pi} \ln \left( 1 + \frac{V_{ds}}{\phi_{bi} - a\phi_s} \right)$$

Taur, Eq. (A9.23)



Potential profile (Taur, Fig. 3.20(b))

# Minimum potential at $y = y_c$

- Using some approximations,

$$\begin{aligned}\phi(0, y_c) &= \phi_s + 2\sqrt{b_1 c_1} \exp\left(-\frac{\pi L}{2\lambda}\right) \sin\left(\frac{\pi 3t_{ox}}{\lambda}\right) \\ &\approx \phi_s \\ &+ \left(\frac{6\pi t_{ox}}{\lambda}\right) \left( \sqrt{\phi_{bi}(\phi_{bi} + V_{ds})} - \frac{2\phi_{bi} + V_{ds}}{2\sqrt{\phi_{bi}(\phi_{bi} + V_{ds})}} a\phi_s \right) \exp\left(-\frac{\pi L}{2\lambda}\right) \\ &\sim \text{Taur, Eq. (A9.24)}\end{aligned}$$

– Threshold voltage lowering,  $\Delta V_t$ ,

$$\begin{aligned}\Delta V_t &= \left(\frac{24t_{ox}}{W_{dm}}\right) \left( \sqrt{\phi_{bi}(\phi_{bi} + V_{ds})} - a(2\phi_B) \right) \exp\left(-\frac{\pi L}{2(W_{dm} + 3t_{ox})}\right) \\ &\sim \text{Taur, Eq. (A9.25)}\end{aligned}$$

# Typical values in the textbook

- Following Taur, Eq. (3.67),

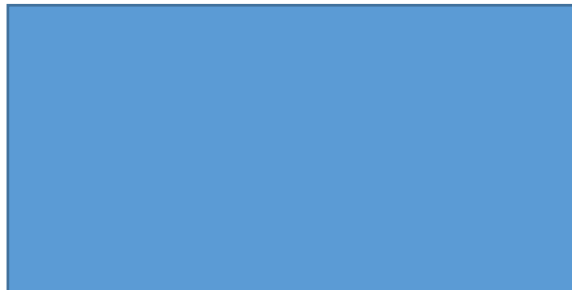
$$\Delta V_t = \left( \frac{24t_{ox}}{W_{dm}} \right) \left( \sqrt{\phi_{bi}(\phi_{bi} + V_{ds})} - a(2\phi_B) \right) \exp \left( -\frac{\pi L}{2(W_{dm} + 3t_{ox})} \right)$$

– Using typical values,

$$0.1 = (2.4)(\sqrt{2} - 0.4) \exp \left( -\frac{\pi L}{2(1.3W_{dm})} \right)$$

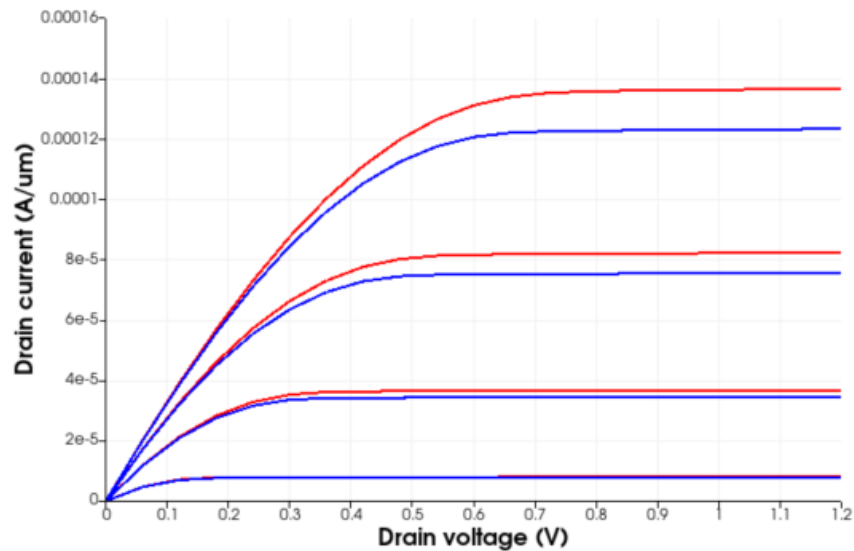
– We get  $L \approx 2.6W_{dm} \approx 2(W_{dm} + 3t_{ox})$ .

– The minimum allowable channel length is  $L_{min} \approx 2(W_{dm} + 3t_{ox})$ .

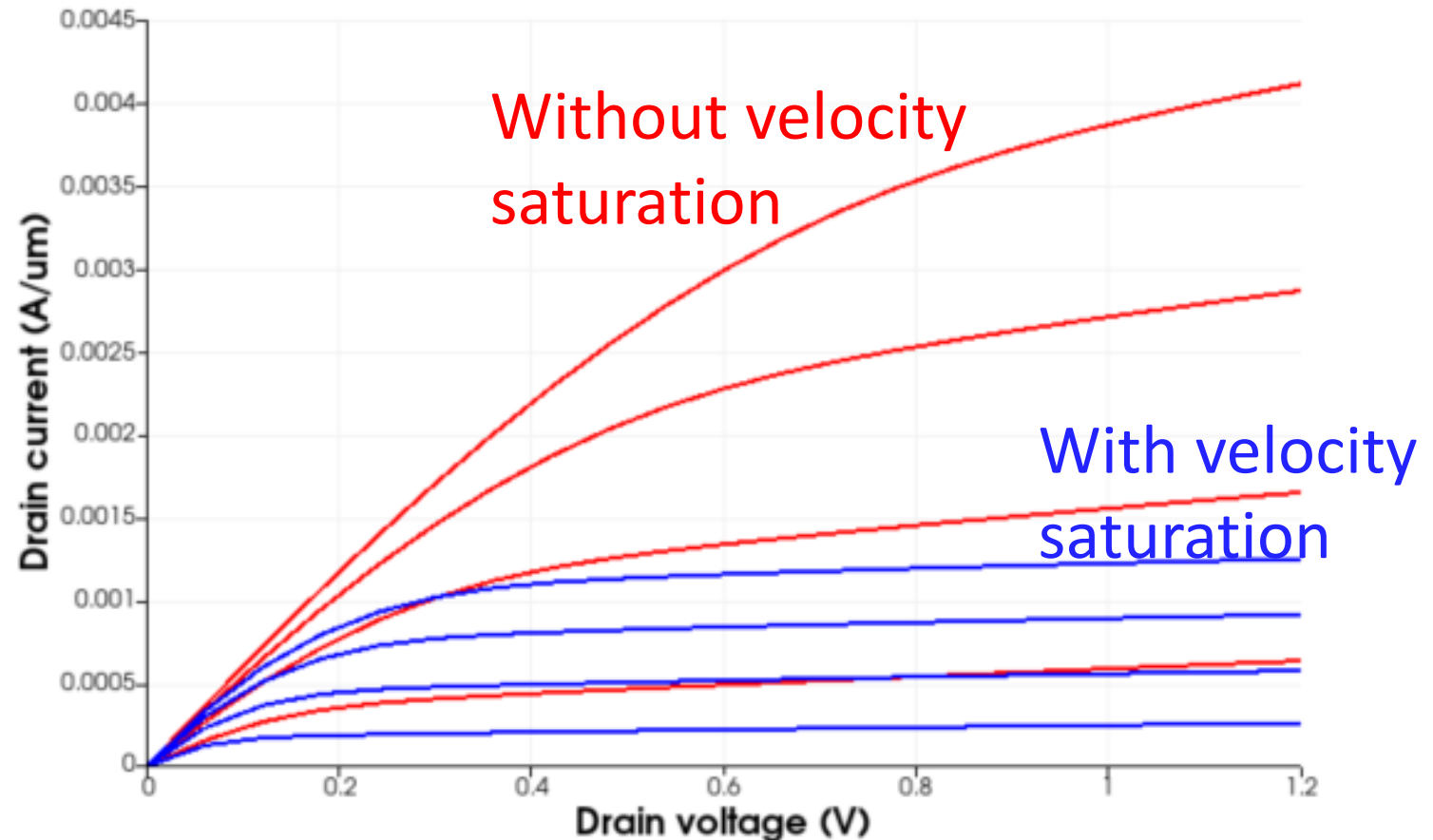


# Velocity saturation

- Impact of velocity saturation
  - Saturation occurs at a much lower voltage (than  $V_{dsat} = (V_{gs} - V_t)/m$ ).



Long-channel





# Velocity-field relationship

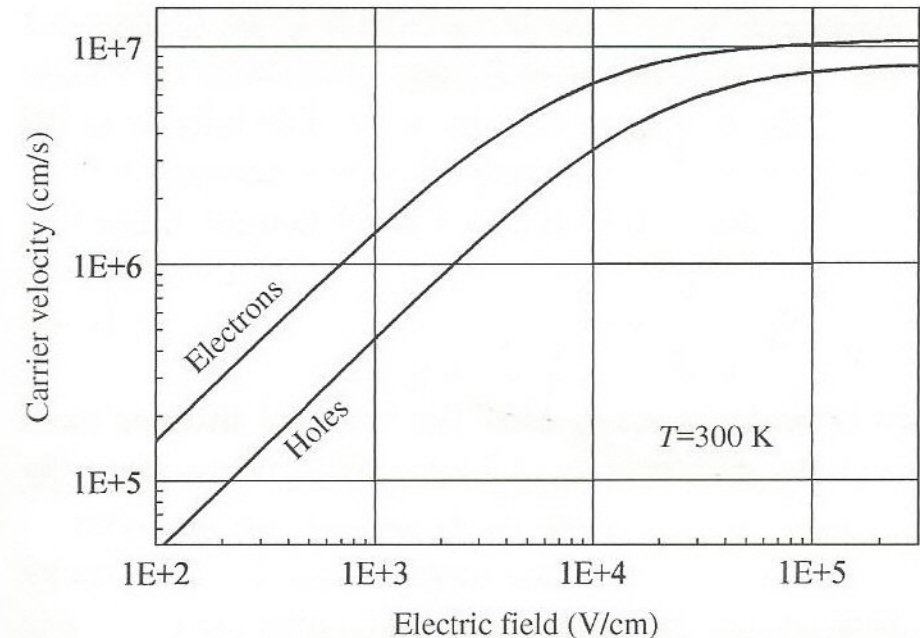
- Caughey-Thomas

- Saturation may occur at a much lower voltage (than  $V_{dsat} = \frac{V_{gs} - V_t}{m}$ ).

$$v = \frac{\mu_{eff} \mathcal{E}}{[1 + (\mathcal{E}/\mathcal{E}_c)^n]^{1/n}}$$

Taur, Eq. (3.71)

- Critical field,  $\mathcal{E}_c$
- For electrons,  $n = 2$ . For holes,  $n = 1$
- At low fields,  $v = \mu_{eff} \mathcal{E}$
- At high fields ( $\mathcal{E} \rightarrow \infty$ ),  $v \rightarrow \mu_{eff} \mathcal{E}_c = v_{sat}$



Velocity-field relationship (Taur, Fig. 2.10)

# Analytic solution for $n = 1$ (1)

- Valid for holes (PMOSFET)

$$I_d = -WQ_i(V) \frac{\mu_{eff} \frac{dV}{dy}}{1 + \left(\frac{\mu_{eff}}{v_{sat}}\right) \frac{dV}{dy}}$$

Taur, Eq. (3.73)

– Rearranging

$$I_d \left[ 1 + \left(\frac{\mu_{eff}}{v_{sat}}\right) \frac{dV}{dy} \right] = -WQ_i(V) \mu_{eff} \frac{dV}{dy}$$

$$\textcolor{red}{I_d} = - \left[ \mu_{eff} W Q_i(V) + \left( \frac{\mu_{eff} \textcolor{red}{I_d}}{v_{sat}} \right) \right] \frac{dV}{dy}$$

Taur, Eq. (3.74)

# Analytic solution for $n = 1$ (2)

- Drain current with velocity saturation

$$I_d dy = - \left[ \mu_{eff} W Q_i(V) + \left( \frac{\mu_{eff} I_d}{v_{sat}} \right) \right] dV$$

– Integration from  $y = 0$  to  $L$  (from  $V = 0$  to  $V_{ds}$ )

$$I_d L = -\mu_{eff} W \int_0^{V_{ds}} Q_i(V) dV - \left( \frac{\mu_{eff} I_d}{v_{sat}} \right) V_{ds}$$

$$I_d L \left( 1 + \frac{\mu_{eff} V_{ds}}{v_{sat} L} \right) = -\mu_{eff} W \int_0^{V_{ds}} Q_i(V) dV$$

$$I_d = \frac{-\mu_{eff} (W/L) \int_0^{V_{ds}} Q_i(V) dV}{1 + (\mu_{eff} V_{ds} / v_{sat} L)}$$

Taur, Eq. (3.75)

# Analytic solution for $n = 1$ (3)

- Using the charge-sheet model

$$Q_i = -C_{ox}(V_{gs} - V_t - mV) \quad \text{Taur, Eq. (3.76)}$$

$$I_d = \frac{\mu_{eff} C_{ox} (W/L) \left[ (V_{gs} - V_t) V_{ds} - \frac{m}{2} V_{ds}^2 \right]}{1 + (\mu_{eff} V_{ds} / v_{sat} L)} \quad \text{Taur, Eq. (3.77)}$$

– By solving  $\frac{dI_d}{dV_{ds}} = 0$  at  $V_{dsat}$ ,

$$0 = \frac{(V_{gs} - V_t) - mV_{dsat}}{1 + (\mu_{eff} V_{dsat} / v_{sat} L)} - \frac{(V_{gs} - V_t) V_{dsat} - \frac{m}{2} V_{dsat}^2}{[1 + (\mu_{eff} V_{dsat} / v_{sat} L)]^2} (\mu_{eff} / v_{sat} L)$$

# Analytic solution for $n = 1$ (4)

- Manipulation

$$\begin{aligned} & [(V_{gs} - V_t) - mV_{dsat}][1 + (\mu_{eff}V_{dsat}/v_{sat}L)] \\ &= \left[ (V_{gs} - V_t)V_{dsat} - \frac{m}{2}V_{dsat}^2 \right] (\mu_{eff}/v_{sat}L) \\ & \quad 2(V_{gs} - V_t)/m \end{aligned}$$

$$V_{dsat} = \frac{2(V_{gs} - V_t)/m}{1 + \sqrt{1 + 2\mu_{eff}(V_{gs} - V_t)/(mv_{sat}L)}} \leq (V_{gs} - V_t)/m$$

Taur, Eq. (3.78)

$$-L \rightarrow \infty, V_{dsat} = (V_{gs} - V_t)/m$$

$$-L \rightarrow 0,$$

$$V_{dsat} = \sqrt{\frac{2(V_{gs} - V_t)v_{sat}L}{\mu_{eff}m}}$$

# Analytic solution for $n = 1$ (5)

- Two extreme cases

- $L \rightarrow \infty$ ,

$$I_{dsat} = \mu_{eff} C_{ox} \frac{W}{L} \frac{(V_{gs} - V_t)^2}{2m} \quad \text{Taur, Eq. (3.80)}$$

- $L \rightarrow 0$ ,

$$I_{dsat} = C_{ox} W v_{sat} (V_{gs} - V_t) \quad \text{Taur, Eq. (3.81)}$$

- In this case,  $I_{dsat}$  is independent of channel length  $L$  and varies linearly with  $V_{gs} - V_t$  instead of quadratically as in the long-channel case.

# Other case, $n = \infty$ (1)

- We are more interested with  $n = 2$ .
  - Although details are different, different models share two extremes:
  - $L \rightarrow \infty$ ,

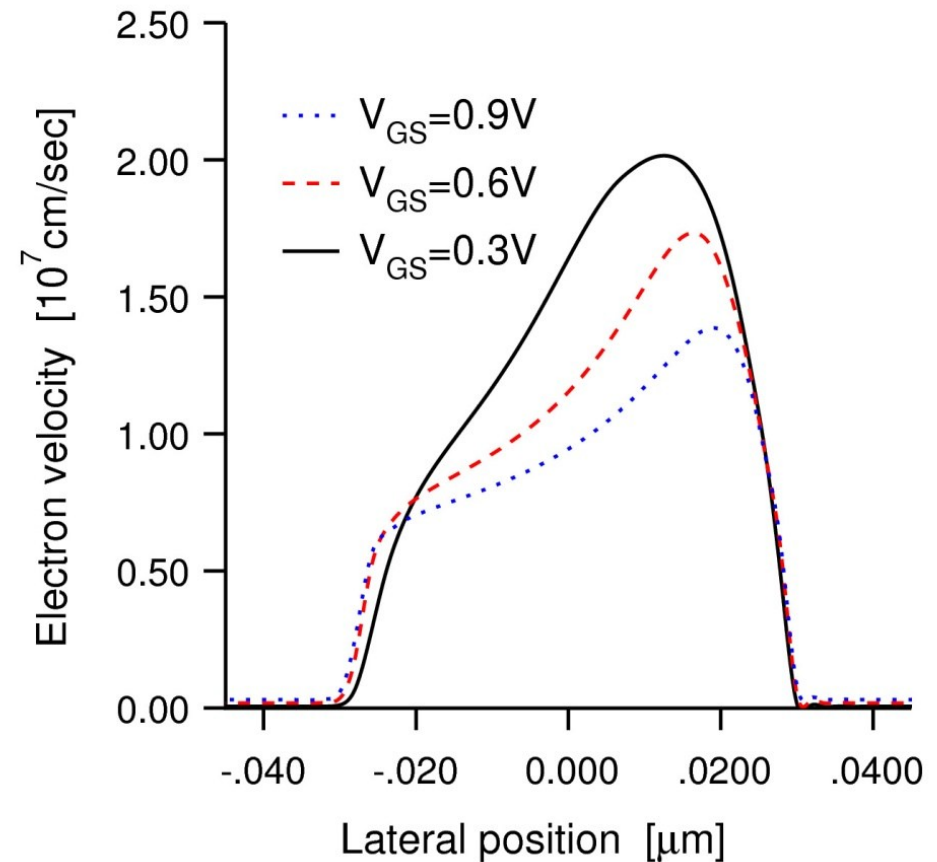
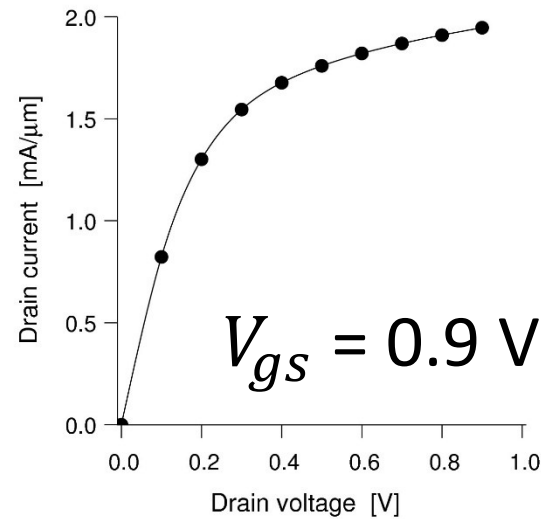
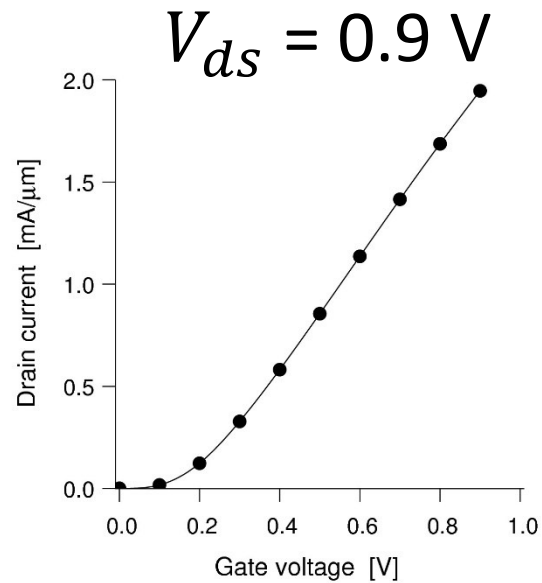
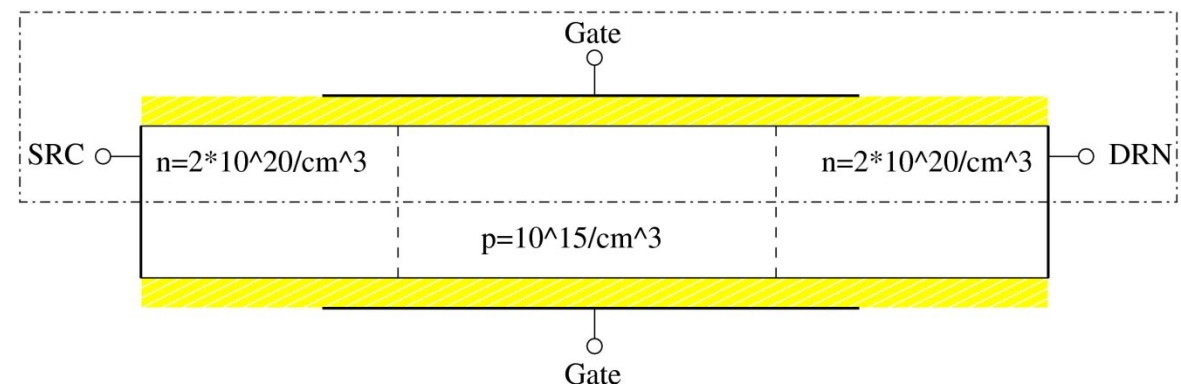
$$I_{dsat} = \mu_{eff} C_{ox} \frac{W}{L} \frac{(V_{gs} - V_t)^2}{2m} \quad \text{Taur, Eq. (3.80)}$$

–  $L \rightarrow 0$ ,

$$I_{dsat} = C_{ox} W v_{sat} (V_{gs} - V_t) \quad \text{Taur, Eq. (3.81)}$$

# Velocity overshoot

- 70-nm-long double-gate MOSFET
  - Strong velocity overshoot





# Thank you!